Docket No.: 42P10058D

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re the Application of:

HAN-MING WU, ET AL.

Application No.:

Filed:

For: Purging Gas from a Photolithography

Enclosure Between a Mask Protective

Device and a Pattern Mask

Art Group:

Examiner:

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §1.97

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the duty of disclosure, enclosed is a copy of Information Disclosure Statement by Applicant (form PTO/SB/08), which is being submitted concurrently with the Divisional Application. It is respectfully requested that the cited references be considered and that the enclosed copy of PTO/SB/08 be initialed by the Examiner to indicate such consideration and a copy thereof returned to applicant(s). Some or all of the references listed on the enclosed PTO/SB/08 were previously identified in the parent application (Application No. 09/752,938, filed December 29, 2000) and copies of the references were furnished at that time. Accordingly, per 37 CFR §1.98(d)(1) additional copies of those references are not submitted herewith.

-1- 42P10058D

The submission of this Information Disclosure Statement is not to be construed as a representation that a search has been made in the subject application and is not to be construed as an admission that the information cited in this statement is material to patentability.

Please charge any fees due to Deposit Account 02-2666. A duplicate copy of the Fee Transmittal (PTO/SB/17) is enclosed for this purpose.

Respectfully submitted,

BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Date: JAN.16, 2004

Brent E. Vecchia, Reg. No. 48,011

12400 Wilshire Boulevard, 7th Floor Los Angeles, CA 90025 Telephone: (303) 740-1980

Substitute for form 1449A/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)					Complete if Known		
				Application Number			
				Filing Date			
				First Named Inventor	Han-Ming Wu		
				Art Unit			
				Examiner Name			
Sheet	1	of	1	Attorney Docket Number	42P10058D		

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.¹	Document Number Number - Kind Code ² (if known)	Publication Date or Issue Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		US-5,453,816	09-26-1995	Wang	
_		US-5,559,584	09-24-1996	Miyaji et al.	
		US-6,153,044	11-28-2000	Klebanoff et al.	
		US-6,317,479	11-13-2001	Chiba et al.	
		US-5,814,381	09-29-1998	Kuo	
		US-5,529,819	06-25-1996	Campi, Jr.	
		US-5,793,836	08-11-1998	Maldonado et al.	
		US-5,422,704	06-06-1995	Sego et al.	
		US-6,542,220	04-01-2003	Schrijver et al.	
-		US-			
		US-			

FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite	Foreign Patent Document	_		Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	1
	No.'	Country Code* - Number* - Kind Code* (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document		T*
						L
						L
						┡
	 					
						\vdash
						
	 					
						
						\vdash

Examiner	Date	
Signature	Considered	

^{*}Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication.

^{&#}x27;Applicant's unique citation designation number (optional). *See Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. *Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). *For Japanese patent documents, the indication of the year of reign of the Emperor must precede the serial number of the patent document. *Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. *Applicant is to place a check mark here if English language Translation is attached.